

Wafer

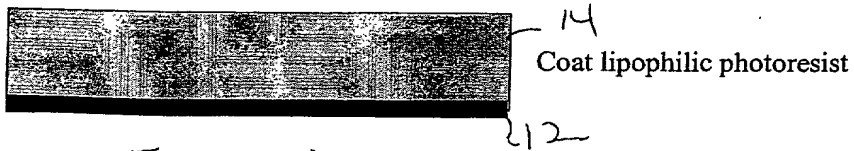


FIG. 1

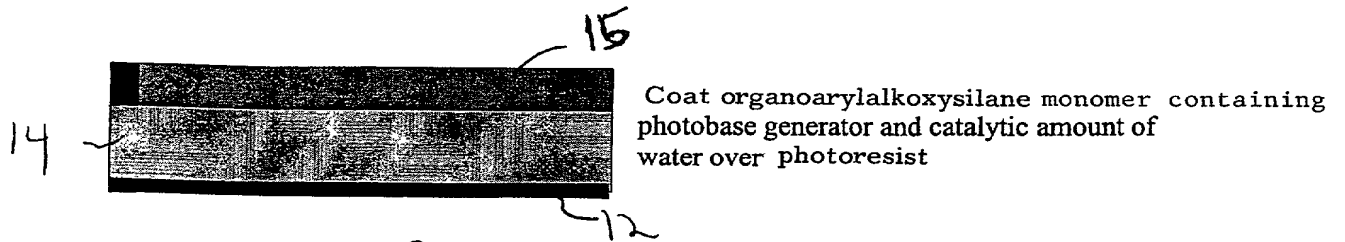
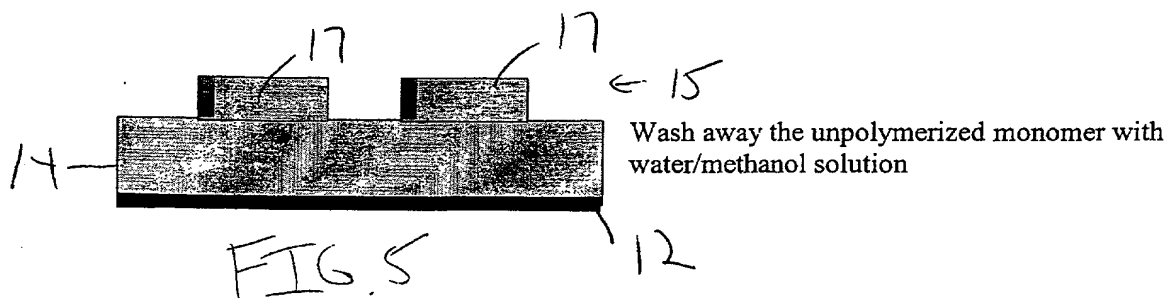
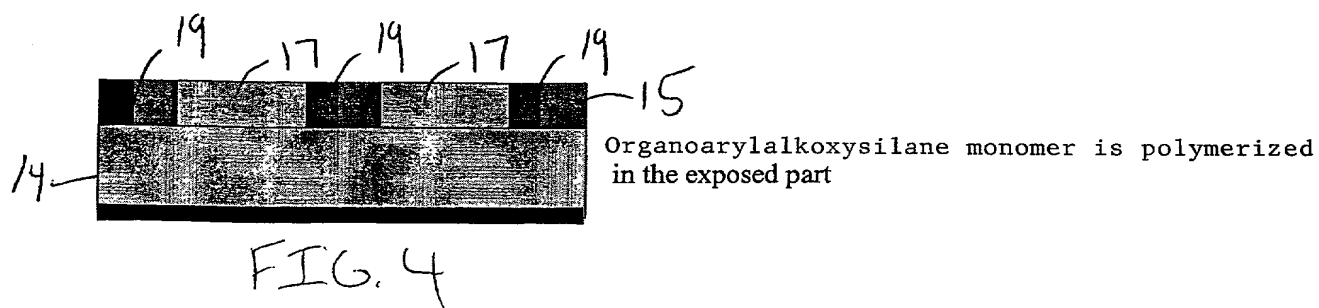
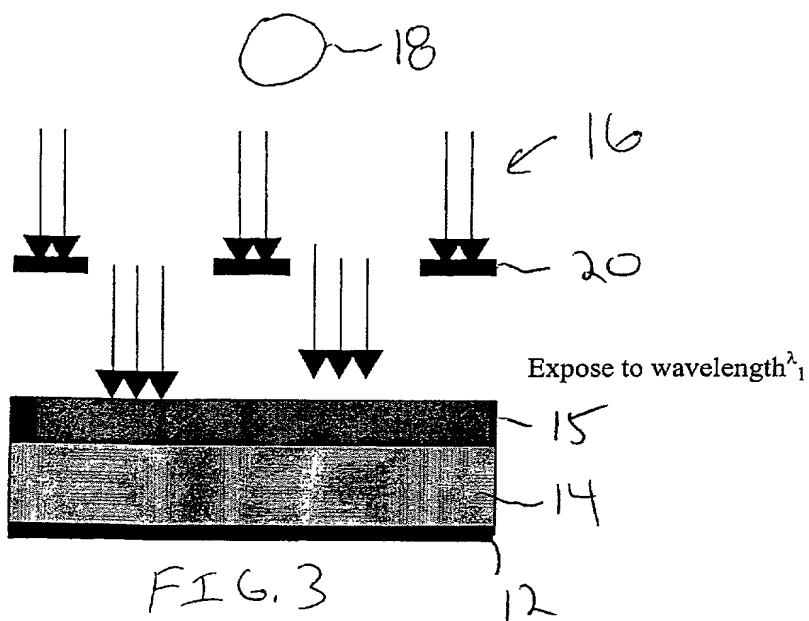
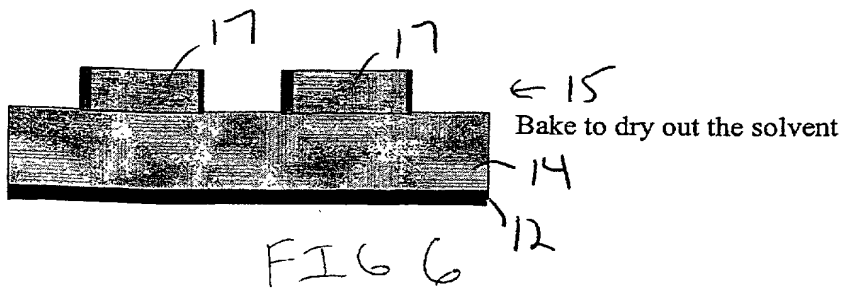
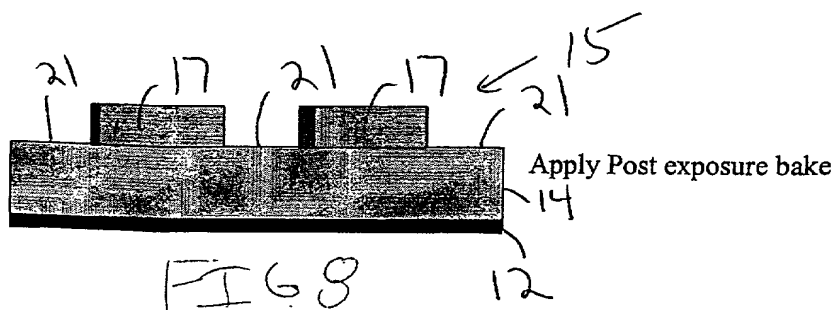
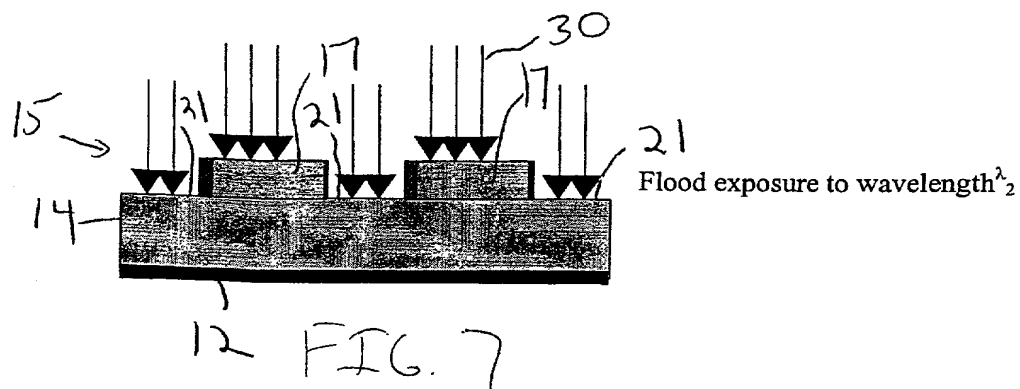


FIG. 2

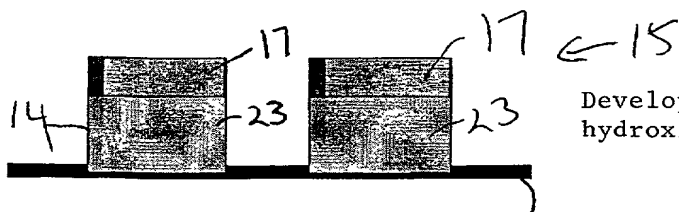




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Develop in tetramethyl ammonium
hydroxide solution

FIG 9 12

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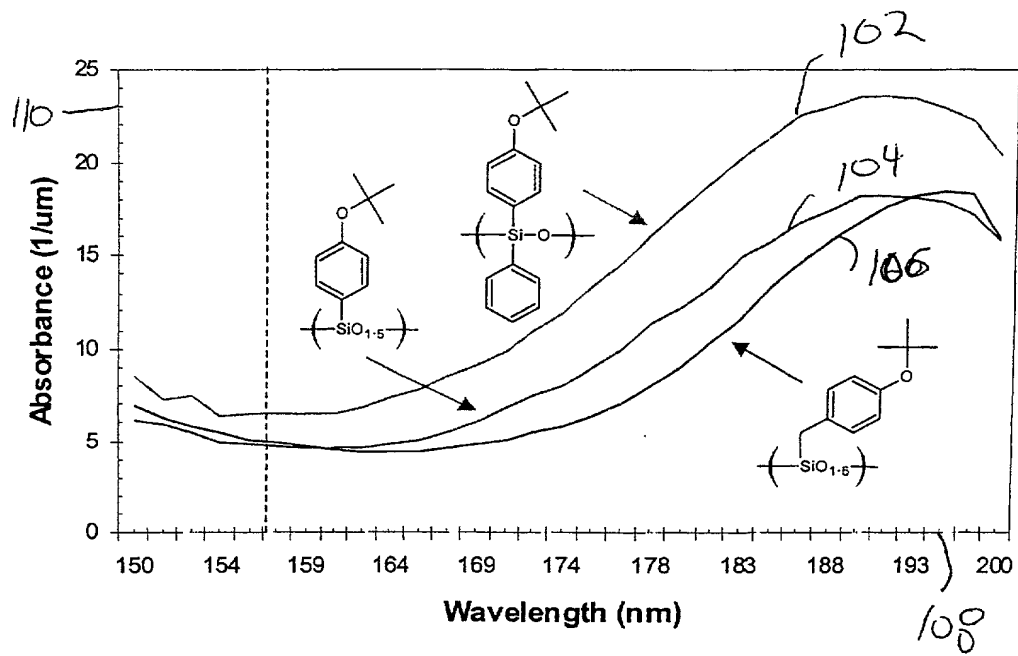


FIGURE 10